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- (71) Applicants (for all designated States except US): FUJI PHOTO FILM CO., LTD. [JP/JP]; 210, Nakanuma, Minami-ashigara-shi, Kanagawa 2500193 (JP). WAKO PURE CHEMICAL INDUSTRIES, LTD. [JP/JP]; 1-2, Doshomachi 3-chome, Chuo-ku, Osaka-shi, Osaka 5408605 (JP).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): SASAKI, Hiroki [JP/JP]; c/o Fuji Photo Film Co., Ltd., 210, Nakanuma, Minami-ashigara-shi, Kanagawa 2500193 (JP). YAMADA, Kohzaburoh [JP/JP]; c/o Fuji Photo Film Co., Ltd., 210, Nakanuma, Minami-ashigara-shi, Kanagawa 2500193 (JP). MAESAWA, Tsuneaki [JP/JP]; c/o Wako Pure Chemical Industries, Ltd., Chemical Products Research Laboratories, 1633, Oaza Matoba, Kawagoe-shi, Saitama 3501101 (JP). ITO, Nobuhiro [JP/JP]; c/o Wako Pure Chemical Industries, Ltd., Chemical Products Research Laboratories, 1633, Oaza Matoba, Kawagoe-shi, Saitama

3501101 (JP). MUTO, Kazushige [JP/JP]; c/o Wako Pure Chemical Industries, Ltd., Chemical Products Research Laboratories, 1633, Oaza Matoba, Kawagoe-shi, Saitama 3501101 (JP).

- (74) Agent: SIKS & CO.; 8th Floor, Kyobashi-Nisshoku Bldg., 8-7, Kyobashi 1-chome, Chuo-ku, Tokyo 1040031 (JP).
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(54) Title: HEAVY-HYDROGENATED (METH)ACRYLATES, PROCESS FOR PRODUCING THEM, POLYMERS THEREOF AND OPTICAL MEMBERS

$$R^{1}$$
 $C=C$ R^{3} [1]

(57) Abstract: A novel compound represented by a formula [1] wherein R¹ and R²respectively represent a heavy or light hydrogen atom, R³ represents a heavy or light hydrogen atom or a methyl group in which three hydrogen atoms are respectively heavy or light hydrogen atoms, R⁴ represents a condensed ring group composed of a norbomane ring and a C₅₋₇ hydrocarbon ring provided that at least one hydrogen atom contained in the condensed ring group is a heavy hydrogen atom;

and a novel polymer produced by polymerization of a composition comprising the compound are disclosed.